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IAP20 Rec'd PCT/PTO 25 JAN 2006

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Appln. of: Mutsuaki Murakami et al.

International

Serial No. PCT/JP2004/010996

U.S. Serial No.: Applied for

Intl. Filing Date: July 26, 2004

U.S. Filing Date: Herewith

Title: METHOD FOR FORMING
OXIDE FILM ON METAL
SURFACE USING IONIC
LIQUID, ELECTROLYTIC
CAPACITOR AND
ELECTROLYTE THEREOF
PRIORITY TO BE CLAIMED

Examiner: Not Assigned

Art Unit: Not Assigned

Attorney Docket No: 5404/130

INFORMATION DISCLOSURE STATEMENT

In accordance with the duty of disclosure under 37 C.F.R. §1.56 and §§1.97-1.98, and more particularly in accordance with 37 C.F.R. §1.97(b), Applicant hereby cites the following reference(s):

U.S. PATENT DOCUMENTS

DOCUMENT NUMBER Number-Kind Code (if known)	DATE	NAME
US 2004/0095708 A1	05/20/2004	Takeda et al.

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER Number-Kind Code (if known)	DATE	COUNTRY
JP 2002-198263 A	07/12/2002	Mitsubishi Chemical Corp.

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OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

International Search Report from Corresponding International Application
No. PCT/JP2004/010996, dated November 22, 2004, 1 page.

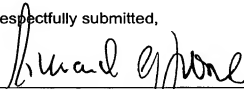
Applicant is enclosing Form PTO-1449 (one sheet), along with a copy of each listed reference for which a copy is required under 37 C.F.R. §1.98(a)(2).

Applicant respectfully requests the Examiner's consideration of the above reference(s) and entry thereof into the record of this application.

By submitting this Statement, Applicant is attempting to fully comply with the duty of candor and good faith mandated by 37 C.F.R. §1.56. As such, this Statement is not intended to constitute an admission that any of the enclosed references, or other information referred to therein, constitutes "prior art" or is otherwise "material to patentability," as that phrase is defined in 37 C.F.R. §1.56(a).

Applicant has calculated no fee to be due in connection with the filing of this Statement. However, the Director is authorized to charge any fee deficiency associated with the filing of this Statement to a deposit account, as authorized in the Transmittal accompanying this Statement.

Respectfully submitted,



Richard G. Lione (Reg. No. 19,795)

Jan. 25, 2006
Date

1AP20R0011067PTO 25 JAN 2006

FORM PTO-1449	INTERNATIONAL APPLICATION NO. PCT/JP2004/010996	CASE NO. 10/565716 5404/130
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT	INTERNATIONAL FILING DATE July 26, 2004	GROUP ART UNIT Not Assigned
(use several sheets if necessary)	FIRST NAMED INVENTOR: Mutsuaki Murakami et al.	
	EXAMINER NAME: Not Assigned	

U.S. PATENT DOCUMENTS

EXAMINER INITIALS	Cite No.	DOCUMENT NUMBER Number-Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Class/Subclass	Filing Date
/NH/	A1	US 2004/0095708 A1	05/20/2004	Takeda et al.		

FOREIGN PATENT DOCUMENTS

EXAMINER INITIALS	Cite No.	Foreign Patent Document Country Code, Number -Number-Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Class/Subclass	T
/NH/	A2	JP 2002-198263 A	07/12/2002	Mitsubishi Chemical Corp.		Abstract

NON PATENT LITERATURE DOCUMENTS

EXAMINER INITIAL	(Include name of author, title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date page(s), volume-issue number(s), publisher, city and/or country where published.					T
/NH/	A3	International Search Report from Corresponding International Application No. PCT/JP2004/010996, dated November 22, 2004, 1 page.				

NOTE: For "T" - please place an "X" if an English translation is being provided to the Patent Office.

EXAMINER /Nguyen Ha/	DATE CONSIDERED 02/18/2008
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.